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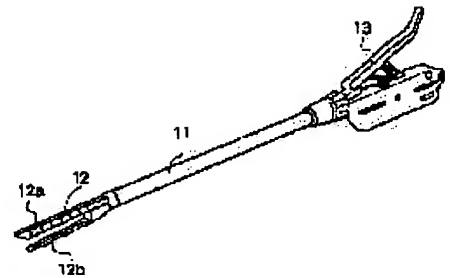
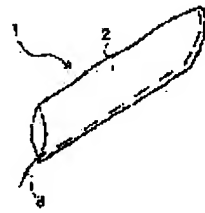
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## (54) SUTURE MATERIAL FOR MEDICAL TREATMENT

## (57)Abstract:

**PURPOSE:** To prevent the occurrence of an inconvenience due to offset or rotation at the time of inserting an automatically suturing unit by sewing a suture material like a bag with the forward end closed, and mounting the sewn material on the automatically suturing unit having a stable line, regarding a medical treatment suture material sewn with the resected part or the like of a bio-tissue.

**CONSTITUTION:** A medical treatment suture material 1 is formed out of a single main suture material 2 made, for example, of a felt of absorptive polyglycolic acid and sewn like a bag with the forward end closed. In other words, the material 2 has length nearly equal to the length of the device part of an automatically suturing unit, and is folded double. Then, the material 2 is stitched with a stitching thread 3 along one breadthwise side thereof. For the thread 3, a monofilament is used for the convenience of extracting the stitches. This type of medical treatment suture material is formed to have a freely opened and closed stitching part 12 at the end of a shaft 11 and fitted to an automatically suturing unit having an operation part 13 at the base end thereof for holding and operation purposes.



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